Resource Summary Report

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ANFF Micro Nano and Semiconductor Patterning

RRID:SCR_012637 Type: Tool

Proper Citation

ANFF Micro Nano and Semiconductor Patterning (RRID:SCR_012637)

Resource Information

URL: http://www.scienceexchange.com/facilities/micro-nano-and-semiconductor-patterning

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Description: The ANFF provides leading-edge research capability and supports excellence in science. The capability provided by ANFF enables users to process hard materials (metals, composites and ceramics) and soft materials (polymers and polymer-biological moieties) and transform these into structures that have application in sensors, medical devices, nanophotonics and nanoelectronics. It has a strong emphasis on service provision to the research community. ANFF seeks to enhance national and international collaborations and enable world-class-research.

Abbreviations: ANFF Micro Nano and Semiconductor Patterning

Synonyms: Australian National Fabrication Facility Micro Nano and Semiconductor Patterning

Resource Type: access service resource, core facility, service resource

Funding:

Resource Name: ANFF Micro Nano and Semiconductor Patterning

Resource ID: SCR_012637

Alternate IDs: SciEx_591

Record Creation Time: 20220129T080311+0000

Record Last Update: 20250505T054202+0000

Ratings and Alerts

No rating or validation information has been found for ANFF Micro Nano and Semiconductor Patterning.

No alerts have been found for ANFF Micro Nano and Semiconductor Patterning.

Data and Source Information

Source: SciCrunch Registry

Usage and Citation Metrics

We have not found any literature mentions for this resource.